



In re patent application of:

Docket No. P26809

T.J. Dalton et al.

Confirmation No. 1180

Appln. No. : 10/604,181

Group Art Unit: 1756

Filed : June 30, 2003

Examiner: Christopher Young

For : METHOD FOR DRY ETCHING PHOTOMASK MATERIAL

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop Amendment  
Randolph Building  
401 Dulany Street  
Alexandria VA 22314

**REQUEST FOR RECONSIDERATION**  
**UNDER 37 C.F.R. §1.111**

Sir:

In response to the Office Action dated April 1, 2005, Applicants request reconsideration of the rejected claims in view of the following remarks.

Remarks begin on page 2 .

Applicants are concurrently filing an extension of time to extend the three-month shortened statutory date of April 1, 2005 by one month to August 1, 2005. If additional extensions of time are necessary to prevent abandonment of this application, then such extensions of time are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefore (including fees for net addition of claims) are hereby authorized to be charged to Deposit Account No. 09-0458.